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Simulations of Inter-Strip Capacitance and Resistance for the Design of the CMS Tracker Upgrade

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In order to address the problems caused by the intense radiation environment, extensive measurements and simulation studies have been initiated for investigating these different design and material options for Silicon micro-strip sensors.

The simulation studies are based on commercial packages (Silvaco and Synopsys TCAD) and aim to investigate sensor characteristics before and after irradiation for fluences up to $1.5 \cdot 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$. A defect model was developed to implement the radiation damage and tuned to fit experimental measurements.

This paper covers the simulation of the inter-strip capacitance and resistance both before and after irradiation. Both properties are crucial for the design of future sensors, being responsible for strip noise and isolation, in turn affecting resolution. A detailed understanding of these parameters is required for an optimal sensor design for the future CMS tracker.

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1. Introduction

The currently installed silicon strip tracker in the CMS detector was designed for a running time of 10 years and a peak instantaneous luminosity of $10^{34} \text{ cm}^{-2} \text{ s}^{-1}$. The upcoming HL-LHC phase will not only increase the instantaneous luminosity by a factor of five, but also create an even harsher radiation environment. An upgraded tracker will therefore experience an increased particle flux and requires increased radiation hardness of sensors. It is planned to use information from the tracker in the first level CMS trigger and to additionally reduce the material budget. The design of new silicon sensors can be enhanced by the use of finite-element Technology Computer Aided Design (TCAD) simulations, which were performed with two commercially available software frameworks, Synopsys Sentaurus¹ and Silvaco Atlas².

The CMS Tracker Collaboration has started a campaign to identify not only properties and production processes of various silicon materials, but also to provide a baseline for a possible future sensor generation [1], complemented by device simulation studies. This ongoing campaign focuses on determining radiation damage effects and annealing behaviour, as well as evaluating sensor geometries and materials.

2. Inter-Strip Capacitance and Resistance

Two important strip sensor characteristics are the inter-strip capacitance C_{int} and inter-strip resistance R_{int} . They are defined as the capacitance or resistance of an individual strip towards its next neighbours. Since these properties contribute to strip noise and strip isolation, respectively, a detailed understanding of these parameters is necessary.

Within the above mentioned campaign, numerous measurements of C_{int} and R_{int} have been performed on dedicated multi-geometry silicon strip detector (MSSD) test sensors. The MSSD sensors have an active thickness from $120 \mu\text{m}$ to $320 \mu\text{m}$ and a strip pitch between $70 \mu\text{m}$ and $240 \mu\text{m}$. By varying the strip implantation width, three width to pitch ratios w/p of 0.15, 0.25 and 0.33 have been realized, for n-type and p-type bulk material, the latter using p-spray and also p-stop strip isolation technology. The strips have a length of $30490 \mu\text{m}$. These measurements can be used as a benchmark to evaluate sensor simulation results. Also, as described in [2], TCAD simulations can be used to estimate unknown sensor geometries. C_{int} and R_{int} are ideal properties to check against, as they are highly dependent on the sensor geometry.

The values for C_{int} between two strips i and j were calculated with the following formula, in accordance with [3]:

$$C_{\text{int}} = C_{\text{AC}_i-\text{AC}_j} + C_{\text{AC}_i-\text{DC}_j} + C_{\text{DC}_i-\text{DC}_j} + C_{\text{DC}_i-\text{AC}_j}$$

$C_{\text{AC}_i-\text{AC}_j}$ is the capacitance measured between the AC contacts of a sensor, $C_{\text{DC}_i-\text{DC}_j}$ between DC contacts. $C_{\text{AC}_i-\text{DC}_j}$ refers to the capacitance between an AC and a DC contact. In the simulation,

¹<http://www.synospys.com>

²<http://www.silvaco.com>

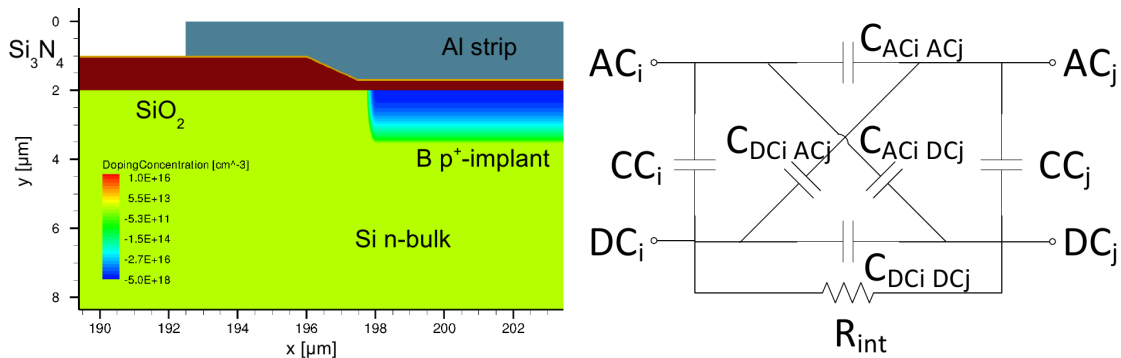


Figure 1: Left: Close-up of the simulated sensor structure. The silicon n-bulk is displayed in green, the boron p^+ -implant in blue. The aluminum read-out strip is grey, with the SiO_2 in red. Note the additional layer of Si_3N_4 in yellow. Right: measurement scheme for C_{int} and R_{int} between two strips with AC contacts AC_i and AC_j and DC contacts DC_i and DC_j .

the AC contact was placed on top of the aluminum read-out strip and the DC contact on the strip implantation.

The inter-strip resistance R_{int} was simulated by biasing the sensor and, after reaching a steady state, applying one volt bias to a strip. The resistance was then calculated by measuring the resulting current on the neighbouring strips.

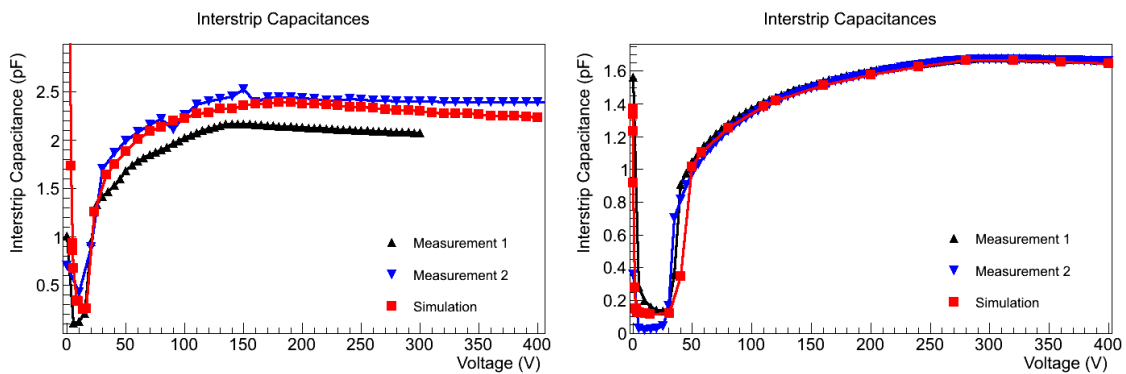


Figure 2: Left: C_{int} dependance on bias voltage for a $200\ \mu m$ thick p-type sensor with p-spray isolation and a pitch of $80\ \mu m$ before irradiation. The simulation in red is in agreement with measurements from different setups. Right: Simulated C_{int} for a $320\ \mu m$ thick n-type sensor with a pitch of $120\ \mu m$ before irradiation, again in agreement with measurements.

In figure 2 two example simulations of C_{int} are shown, for both n- and p-bulk material, different thicknesses and pitch values. In both cases, the simulated results are in good agreement with the measurements. Simulated C_{int} vs. bias voltage curves also reproduce measurements for all other geometric MSSD variations. From this it can be concluded that the basic structure shown in figure 1 is a valid representation of the MSSD devices. Figure 3 shows simulated R_{int} vs. bias voltage curves for a $200\ \mu m$ thick p-on-n sensor before irradiation, in agreement with the measurement values.

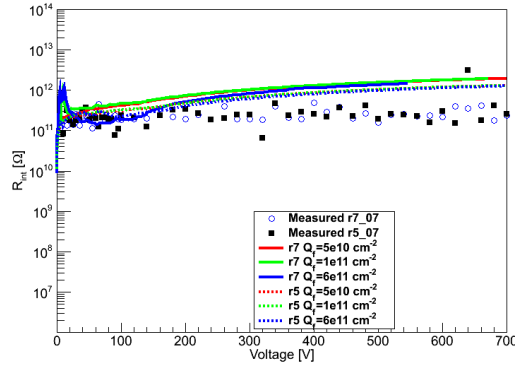


Figure 3: Inter-strip resistance R_{int} dependance on bias voltage for different values of Q_f .

3. Inter-Strip Capacitance and Inter-Strip Resistance for Irradiated Sensors

Radiation damage is included in TCAD simulations by introducing traps, which are energy states in the silicon bandgap and can account for bulk damage. Surface damage is implemented by defining an interface charge Q_f at the Si - SiO₂ interface. A bulk damage trap is defined by its energy E , concentration c or introduction rate η (with $c = \eta \cdot \Phi$, Φ being the fluence) and its capture cross-sections σ_n and σ_p for electrons and holes, respectively. Depending on radiation type and simulation software there are several models in existence [4]. For fluences as high as expected for HL-LHC operating conditions, a combination of bulk and surface damage is necessary. The following simulations were performed with the model described in table 1 using Silvaco Atlas [5].

Type	Energy in eV	σ_n in cm ²	σ_p in cm ²	c in cm ⁻³
Acceptor	$E_c - 0.525$	$1 \cdot 10^{-14}$	$1.4 \cdot 10^{-14}$	$3 \cdot \Phi$
Acceptor	$E_c - 0.45$	$8 \cdot 10^{-15}$	$2 \cdot 10^{-14}$	$40 \cdot \Phi$
Acceptor	$E_c - 0.40$	$8 \cdot 10^{-15}$	$2 \cdot 10^{-14}$	$40 \cdot \Phi$
Donor	$E_v + 0.50$	$4 \cdot 10^{-15}$	$4 \cdot 10^{-15}$	$0.6 \cdot \Phi$
Donor	$E_v + 0.45$	$4 \cdot 10^{-15}$	$4 \cdot 10^{-15}$	$20 \cdot \Phi$

Table 1: Used bulk damage model for proton irradiation with Silvaco Atlas.

After including radiation damage in the simulation, C_{int} and R_{int} change, as is shown in figure 4 for various simulations and measured data. The inter-strip resistance drops to several GΩ and the voltage behaviour of C_{int} flattens out. As can be seen in both cases, it is essential to include surface damage in the form of an interface charge Q_f alongside bulk damage to reproduce measurement values.

4. Summary and Conclusion

It has been shown that experimental measurements of inter-strip capacitance and resistance on MSSD sensors can be reproduced before and after irradiation by using an effective bulk damage

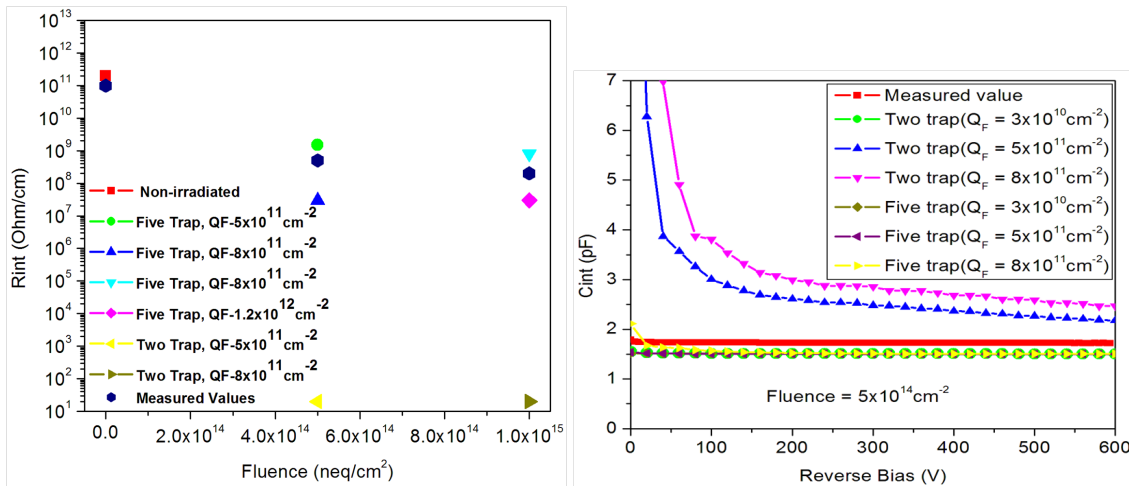


Figure 4: Left: R_{int} for different fluences and values of Q_F . Right: Simulated C_{int} for a 200 μm thick p-type sensor after irradiation with a fluence of $5 \cdot 10^{14} \text{ neq/cm}^2$.

model and including surface damage. Further work in this area [5] [6] shows that measurements of other sensor properties, such as leakage current, charge collection efficiency and depletion voltage can also be reproduced, both before and after including radiation damage. This could provide TCAD simulations with predictive power in contributing to the design of future sensors, not only for strip trackers but also for detectors in even higher radiation environments, such as pixel detectors.

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